MAKING METHOD OF MICRO-LENS

Patent Number: Publication date: KR9405965 1994-08-25

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Requested Patent: KR9405965

KR19910017124 19910930 Application Priority Number(s): KR19910017124 19910930 G02B5/20

IPC Classification:

EC Classification:

Equivalents:

Abstract

The method for increasing the incident light amount comprises the steps of: a) overlapping the micro lens onto the pixel, which width and length sides are different from each other, in direction of the short side, b) narrowing the short side of the black part rather than the long side to form the clear part; c) reflowing them thermally with a transparent photoresist; and d) forming the micro lens by depositing the photoresist deeply to have the curvature of the long and short axes to be the

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